

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: Pelham and Burr

Serial: 10/772,029

Group Art Unit: 2892

Filed: February 3, 2004

Examiner: Luu, C. A.

For: METHOD FOR GENERATING A DEEP N-WELL PATTERN FOR  
AN INTEGRATED CIRCUIT DESIGN

Honorable Commissioner for Patents  
PO Box 1450  
Alexandria, VA 22313-1450

SUPPLEMENTAL AMENDMENT and RESPONSE

Dear Sir:

In response to the proposed rejection communicated by the Examiner on May 5, 2009 in the above captioned case, Applicants respectfully request the Examiner to enter the following amendments and to consider the following remarks.